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Original article

Isolation and Identification of Microorganisms associated with high-quality and low-quality cosmetics from different brands in Mecca region -Saudi Arabia

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ARTICLE INFO	A B S T R A C T
<i>Keywords:</i> High-quality cosmetics Low-quality cosmetics Fungal and bacterial contamination	Cosmetic products contain several components that are ideal for microbial growth, they exposed to contami- nation by pathogenic bacteria and fungi, and this may cause health risks such as skin and eye infections. In this investigation, 50 samples were obtained from various shops in Mecca region, Saudi Arabia. Collected samples include high-quality and low-quality brands of makeup. Results show that most cosmetics are contaminated with microorganisms. Bacterial and fungal isolates were identified by morphological and microscopic techniques, and confirmed by molecular methods: (16s rRNA) for bacterial isolates and (18s rRNA) for fungal isolates associated with cosmetics. In low-quality cosmetics, frequency of microbial growth is higher and more diverse than high- quality cosmetics. It has been observed the most contaminated product was in lip gloss and it follows by the lipstick. The most predominant species of bacteria are <i>Staphylococcus aureus</i> (27 %), <i>E. coli</i> (27 %), which follows by <i>Streptococcus pneumonia</i> (18 %), <i>Staphylococcus epidermis</i> (17 %), <i>Bacilli subtilis</i> (12 %), and <i>Pseudomonas</i> <i>aeruginosa</i> (5 %). <i>Aspergillus</i> sp is the most predominant fungi (57 %), which is followed by <i>Penicillium sp.</i> (29 %) and <i>Rhizopus</i> sp. (14 %). In high quality brands, the frequency of microbial growth was the highest in mascara, lip-gloss. The most predominant species of bacteria is <i>Staphylococcus aureus</i> (41 %), which follows by <i>Bacilli</i> <i>subtilis</i> and <i>Pseudomonas aeruginosa</i> and <i>E. coli</i> (17 %). <i>Streptococcus pneumonia</i> is the less dominant (5 %). There is no growth on media of fungi. Due to the large number of cosmetics brands in Mecca region and for consumer safety, this study is prepared.

1. Introduction

Cosmetics are synthetic or natural substances for use on various regions of the human body skin including (lips – eyes) (Oliveira et al., 2020). Cosmetics are produced in large numbers of brands, with different prices and quality. They are used regardless of whether they are safe or unsafe. They may have been contaminated during manufacture or storage. The majority of cosmetics are not sterile and are derived from non-sterile basic materials (Choubey and Godbole, 2017). Most cosmetic products contain several components that are favorable for microbial growth since they are not often manufactured in a media that is sanitized against microbial growth. Items could be contaminated in the factory (Siegert et al., 2005). Bacteria, notably *Enterobacteria* and *Staphylococci* are the most studied microbes polluting composition (Bashir and Lambert, 2020; Dashen et al., 2011). Pathogenic bacteria found in beauty products include *Pseudomonas aeruginosa* and *Staphylococcus aureus* (Sreeparna et al., 2017; Detmer et al., 2010). The most common bacteria that cause human diseases, such as skin infections, were *Staphylococcus epidermidis* and *Staphylococcus aureus*. Pathogenic filamentous fungi are of particular interest since they are linked to opportunistic infections as well as mycotoxin toxicity (Peraica et al., 1999; Hayleeyesus and Manaye, 2014).

Raw materials for cosmetics may be polluted in the first place. Additionally, water used in non-sanitized production may be contaminated. Such circumstances provide an ideal setting for microbial growth. Makeup can have negative effects on women's health if not handled properly. Cosmetic contamination can cause some kinds of infections ranging from mild to severe. There are two key reasons for needing conservatives: to prevent goods from being spoiled by microbes and to prevent disease caused by microbes (Nasir and Qasim, 2020). Cosmetics also contain a wide range of chemicals such as fragrances, preservatives, pigments and other substances known as skin sensitizers which are

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Table 1	
Group (1): Cosmetics products - low quality brands.	

Sample number	Cosmetic category	Number of samples collected	Expiry date	Country of region
1	Lipsticks	4	9/2024	China
2			9/2024	China
3			-	China
4			-	China (P.R.C)
5	Lip-gloss	5	7/2026	China
6			5/2024	China
7			4/2025	China
8			4/2026	China
9			4/2025	China
10	Powders	3	9/2024	China
11			8/2022	China
12			After used	England
			(30 month)	
13	Plusher	2	12/2023	China
14			After used	Italy
			(24 months)	
15	Mascara	3	After used	China
			(6 months)	
16			5/2026	China
17			9/2026	China
18	Foundation	3	After used	France
			(12 months)	
19			After used	USA
			(12 months)	
20			After used	France
			(12 months)	
21	Concealer	3	12/2023	China
22			_	_
23			7/2024	China
24	Eye pencil	2	4/2025	China
25	-		5/2025	China
26	Eye liner	2	6/2026	China
27	Eye Shadow	3	10/2026	China
28	-		3/2024	China

Table 2Group (2): Cosmetics products high-quality brands.

Sample number	Cosmetic category	Number of Collected samples	Expiry date	Country of region	
29	Lipsticks	3	10/2023	France	
30	-		09/2023	Italy	
31			11/2023	USA	
32	Lip-gloss	3	2/2023	UK	
33			11/2024	France	
34			10/2023	USA	
35	Powders	3	08/2024	Italy	
36			09/2024	USA	
37			11/2023	UK	
38	Plusher	2	08/2024	France	
39			09/2024	USA	
40	Mascara	3	12/2023	France	
41			11/2024	USA	
42			01/2024	Italy	
43	Foundation	3	09/2023	France	
44			07/2024	USA	
45			03/2024	Hong Kong	
46	Concealer	1	09/2023	Poland	
47	Eye pencil	2	08/2024	Uk	
48			03/2024	France	
49	Eye Shadow	2	08/2024		
	-			Germany	
50			02/2024		

potentially harmful on general health (Panico et al., 2019). Microbial contamination of cosmetic products is a serious concern for the business, and it has the potential to be a major cause of both economic and product losses. Cosmetics are prone to microbial growth due to the presence of nutrients and water. Microorganisms are frequently the

cause of organoleptic changes such as changes in color, viscosity, and disagreeable odors (Becks and Lorenzoni 1995; Behravan et al., 2005).

Furthermore, in rare situations, contaminated bacteria or their activities may cause human health concerns such as allergic contact dermatitis, skin irritation, and infection, particularly in the mouth, eyes,

Cosmetics samples products with microbial contamination in low-quality makeup.

Cosmetics Category	Number of samples	Media type				
		Nutrient Agar	Blood Agar	MacConkey Agar	Potato dextrose Agar	
Lipsticks	1	S.aureus	S.aureus	Pseudomonas aeruginosa	_	
•	2	_	_	Pseudomonas aeruginosa	_	
	3	_	Streptococcus pneumonia	Pseudomonas aeruginosa	+ Aspergillus	
	4	_	_	_	_	
Lip-gloss	5	Staphylococcus epidermidis	_	_	_	
	6	E. coli	Staphylococcus epidermidis	_	_	
	7	Staphylococcus aureus	Streptococcus pneumonia	_	_	
	8	Staphylococcus aureus	Staphylococcus aureus	_	-	
	9	-	Staphylococcus aureus	_	+ Aspergillus	
Powders	10	Staphylococcus epidermidis	_	_	+ Penicillium sp	
	11	Streptococcus pneumonia	Staphylococcus aureus	Escherichia coli	_	
	12	_	_	_	-	
Plusher	13	Staphylococcus aureus	Staphylococcus aureus	Escherichia coli	+ Aspergillus	
	14	-	Staphylococcus aureus	Escherichia coli	-	
Mascara	15	_	-	_	_	
	16	-	-	_	-	
	17	_	_	_	_	
Foundation	18	_	Bacilli (G +)	_	+Rhizopus	
	19	_	_	_	-	
	20	Staphylococcus epidermidis	_	E. coli	+ Aspergillus	
Concealer	21	E. coli	_	E.coli	-	
	22	_	_	_	_	
	23	Streptococcus pneumonia	_	_	_	
Eye pencil	24	-	_	_	-	
J - I	25	_	_	E. coli	+ Penicillium sp	
Eye liner	26	Staphylococcus aureus	Staphylococcus aureus	_	-	
Eye Shadow	27	Streptococcus pneumonia	_	_	_	
_,	28	Staphylococcus aureus	_	_	_	

No growth (-).

Table 4

Microorganisms in the samples from cosmetics products in low-quality makeup.

Cosmetics category	Bacterial isolates	Fungal isolates
Lipsticks	Staphylococcus aureus., Streptococcus pneumonia, Bacillus subtilis. Pseudomonas aeruginosa	Aspergillus sp
Lip-gloss	Staphylococcus aureus, Staphylococcus epidermidis, Escherichia coli, Streptococcus pneumonia	Aspergillus sp
Powders	Staphylococcus aureus, Staphylococcus epidermidis, Escherichia coli.	Penicillium sp
Plusher	Staphylococcus aureus, Escherichia coli.	Aspergillus sp.
Mascara		_
Foundation	Bacilli subtilis, Staphylococcus epidermidis, Escherichia coli.	Aspergillus sp, Rhizopus sp
Concealer	Streptococcus pneumonia, Escherichia coli	_
Eye pencil	Escherichia coli.	Penicillium sp
Eye liner	Staphylococcus aureus	_
Eve Shadow	Staphylococcus aureus, Streptococcus pneumonia	_

or wounds (Orús et al., 2015). Cosmetics are exposed to contamination by microorganisms and may cause health risks such as skin and eye infections. In fact, a lot of microbes can enter the product via hand and mouth (Siegert, 2013; Dadashi and Dehghanzadeh, 2016). Occurrence of microbes is caused by two major factors: The first is a result of improper application of cosmetics or a failure to follow adequate hygiene procedures. Even though the products contain preservatives, this enables the deposit of skin-derived detritus, which favors the development and spread of microorganisms. The dispersed particles in indoor air, which include dust, bacteria, and spores, are the second and most significant cause of microbial proliferation in cosmetics (Oliveira et al., 2020).

Cosmetics need to be clean and healthy by adding preservative substances both to prevent contamination and financial loss. The additives used in the products should not be harmful to customers because the majority of the beautifying agents were used in delicate areas (Siya et al., 2019). Additionally, particularly in humid conditions, poor air quality has a significant impact on the growth of microbes in cosmetics (Mohammed et al., 2021). Lack of attention to proper manufacturing practices, insufficient preservation systems, insufficient microbiological test procedures, and/or insufficient microbial limits for finished products are thought to be the causes of contamination (El-Bazza et al., 2009).

Therefore, a good cosmetic product will contain a good preservative system that will last for a given period of time indicated by expiry dates. Expiry date on cosmetics indicates that after the given date the product may be altered and is risky to use (Nuzhath, 2014). These preservatives are different ingredients added to cosmetics, some of them are synthetic organic compounds like petrolatum chemicals such as Parabens, Formaldehyde, Paraformaldehyde, Mercury, Butylated Hydroxy anisole (BHA), Butylated Hydroxytoluene (BHT), PEGs, cocamide DEA and toluene (EWG, 2020). Other ingredients are natural like water and oils (Halla et al., 2018).

Under the proper physicochemical circumstances all products including cosmetics containing water and inorganic/organic compounds are exposed to microbial contamination in order to ensure



Chart 1. Frequency of microbial growth in low-quality makeup.



Chart 2. Percentage of bacterial growth in low-quality makeup.

microbiological safety of cosmetics products. This inhibition should have a broad range of activity effectiveness and should last for a longer period of time than the cosmetic product itself, which would be similar to the projected shelf-life plus the consumption time. As a result, all possible sources of contamination must be identified and monitored (Choubey and Godbole, 2017).

Generally, microbial contamination of cosmetics can be one of these reasons (1) raw material evaluation and control, (2) manufacturing process, (3) final product delivery and finally, (4) consumer use to prevent microbial contamination without causing the product's properties (Halla et al., 2018). Due to the large number of cosmetics brands in Mecca region and for consumer safety, the study's primary goals are to: a) assess the level of microbial contamination in high-quality and low-quality cosmetics, b) isolation and identification of microorganisms from unused different brands of cosmetics.

2. Materials and methods

2.1. Samples collection

A total of 50 unused cosmetic samples were collected from different shops in Mecca region, it is situated in the western part of KSA, at a longitude of 39.826168 East and a latitude of 21.422510 North. Collected samples were divided into two groups regarding to their quality; Low- quality brands (Table 1) and High -quality brands (Table 2), the products were separated by number, from 1 to 28 for low quality products: (4) lipsticks, (5) lip-glosses, (5) powders, (3) mascara, (3) liquid foundation, (3) concealers, (2) eye- pencils, (1) eye-liner, (3) eye shadows. Samples from 29 to 50 are high quality products as a follow: (3) lipsticks, (3) lip-glosses, (3) powders, (3) mascara, (3) liquid foundation, (1) concealers, (2) eye- pencils, and (3) eye shadows. Samples were put in sterile plastic bags and transferred to the lab. Each category of cosmetics was numbered and labeled with information like brand, expiration date and country of origin.



Chart 3. Percentage of fungal growth in low-quality makeup.



Chart 4. Frequency of bacterial growth in high-quality makeup.

2.2. Media for growing microorganisms associated with cosmetics

Three different media were used to isolate pathogenic bacteria. These media are: (1) Nutrient agar, NA is medium used for growing bacteria. The chemical composition of this medium is (g/L): NaCl (5.0), yeast extract (2.0), beef extract (1.0), peptone (5.0), and agar (15.0), pH 7.4; (2) MacConkey agar is a differentiated and selective medium used for growing gram-negative bacteria. It containing of (g/l): peptone (17), agar (15), toluene (0.03), protease peptone (3), NaCl (5), methyl violet (0.001), pH 7.1; (3) Blood agar is also a differentiated and selective medium used for growing bacteria. The chemical composition (g/l): blood agar base (950) that contains NaCl (5.0 g), pantone (10.0), agar

(15.0 g), beef heart (3.0), cornstarch (1.0 g), and sheep blood (50.0), pH 7.4.

For fungi, Potato Dextrose agar is used for growing fungi and yeast. The chemical composition is (g/ liter): Potato infusion (200), Dextrose (20), and agar (20).

2.3. Isolation of microorganisms

To isolate microorganisms we follow procedures specified in Chapter 23 of the FDA's Bacteriological Analytical Manual (BAM) for isolating bacteria and fungi procedure associate with cosmetics (https://www.fd a.gov/food/laboratory-methods-food/bam-chapter-23-methods-cosmet

Microbial contamination in the samples from unused cosmetics products in high-quality makeup.

Cosmetics category	Number of samples	Media type					
		Nutrient Agar	Blood Agar	MacConkey	Potato dextrose Agar		
Lipsticks	29	Staphylococcus aureus	-	-	-		
	30	_	_	_	_		
	31	Staphylococcus aureus	_	_	-		
Lip-gloss	32	Staphylococcus aureus	+ Bacillus sp (G +)	_	-		
	33	_	_	_	-		
	34	_	_	_	-		
Powders	35	-	Staphylococcus aureus	_	-		
	36	_	_	_			
	37	Staphylococcus aureus	_	_	-		
Plusher	38	_	Staphylococcus aureus	_	-		
	39	_	_	Escherichia coli			
Mascara	40	Staphylococcus epidermidis	_	_	-		
	41	_	_	Pseudomonas aeruginosa			
	42	_	Streptococcus pneumonia	_	_		
Foundation	43	Staphylococcus aureus	_	_	_		
	44	_	_	_	_		
	45	Staphylococcus aureus	_	_	_		
Concealer	46		+ Bacillus sp (G +)	_	_		
Eye pencil	47	_	_	Pseudomonas aeruginosa	_		
	48	_	_	Pseudomonas aeruginosa			
Eye Shadow	49	_	Staphylococcus aureus	-	_		
•	50	Staphylococcus aureus	-	-	-		

*No growth (-).

Table 6

Bacterial contamination in the samples from unused cosmetics products in highquality makeup.

Cosmetics category	Bacterial isolate		
Lipsticks	Staphylococcus aureus		
Lip-gloss	Staphylococcus aureus, Bacillus subtills		
Powders	Escherichia coli		
Plusher	Staphylococcus aureus, Escherichia coli		
Mascara	Staphylococcus aureus, Streptococcus pneumonia		
Foundation	Staphylococcus aureus		
Concealer	Bacillus subtills		
Eye pencil	Pseudomonas aeruginosa		
Eye Shadow	Pseudomonas aeruginosa		

ics) (FDA, 2022). In the beginning, to clean each cosmetic, a sterile cotton swab was utilized such as mascara, lip gloss, powders, and lipstick. Cotton swab was taken and added to 10 ml of sterile saline was used to dilute the solution, which was then mixed in the vortex for 10 min. To make 10^{-1} dilutions, 1 ml of sample solution and 9 ml of saline

Table 7

Average of bacterial counts (CFU $/10^{-5)}$ in low-quality brands of collected cosmetics.

Cosmetics category	Bacterial isolates CFU (10 ⁻⁵ /ml)	Fungal isolates CFU (10 ⁻⁵ /ml)	
Lipsticks	251	<10	
Lip-gloss	300	<10	
Powders	212	<10	
Plusher	198	33	
Mascara	ND	ND	
Foundation	119	<10	
Concealer	73	ND	
Eye pencil	21	<10	
Eye liner	39	ND	
Eye Shadow	65	ND	

*ND (not detected).

solution were added to a fresh test tube. Dilutions of 10⁻¹, 10⁻², 10⁻³, 10⁻⁴, and 10⁻⁵ were created. For liquid product like foundation and concealer 1 ml transfer to 10ml of sterile saline to make a dilute solution,



Chart 5. Percentage of bacterial growth in high-quality makeup.

Average of bacterial counts (CFU /10-5) in high-quality brands of	
collected cosmetics.	

Cosmetics category	Bacterial isolates CFU 10 ⁻⁵ /ml
Lipsticks	89
Lip-gloss	110
Powders	77
Plusher	95
Mascara	300
Foundation	103
Concealer	<10
Eye pencil	33
Eye liner	57
Eye Shadow	68

and the same serial dilution procedure was followed until concentrtion 10^{-5} . The culture dishes were incubated at 37 °C for 48 h. Most culture media showed bacterial colony development after incubation, for fungi the culture dishes were incubated at 25 °C for one week after inoculation. The total number of colonies was determined as (CFU ml⁻¹) after the incubation time. The colonies were then sub cultured on nutrient agar dishes. Each colony underwent this technique three times to confirm the purity of each isolated bacteria.

2.4. Identification of microorganisms associated with cosmetics

2.4.1. Bacteria

Bacteria were identified based on morphological traits as reported in the 8th edition of Bergey's Manual of Determinative Bacteriology (Bergey and Holt, 2000). Bacteria identified by describing colonies growing on different plates, Gram staining and shapes under the microscope (Noor et al.,2020). Oxidases, catalase, and the analytical profile index (API-20E kit) are further biochemical tests. The kits contain up to 20 biochemical tests, gelatinase, arginine Di hydrolase, â-galactosidase enzyme, Voges-Proskauer test, citrate test, lysine decarboxylase, urea hydrolysis, ornithine decarboxylase, H₂S production, indole test, tryptophan deaminase, as well as sugars (amygdalin, mannose, rhamnose, sorbitol, inositol, sucrose, arabinose, glucose, and melibiose) fermentation.

2.4.2. Fungi

Colonies of fungi were identified based on their microscopic and macroscopic appearance, reference to manuals of Barnett and Hunter (1972). Fungal filaments were stained by lactophenol.

2.5. Molecular Identification of bacteria 16S rRNA sequences

A) DNA extraction: by using protocol of Gene Jet genomic DNA purification Kit (Thermo Fisher Scientific) after harvesting up of bacterial (2x10⁹) cells by centrifugation for 10 min at 5000 × g.
 B) PCR amplification:



Fig. 1. Different genera of bacteria isolated from low-quality cosmetics products; (A) Streptococci, (B) Staphylococci, and C) Bacillus sp.



Fig. 2. Fungal cultures isolated from low-quality cosmetics products in culture medium; (A) Penicillium sp., (B) Aspergillus, and (C) Aspegillus fumigatus.



Fig. 3. Fungi isolated from low-quality cosmetic products; (A) Aspergillus sp., (B)Penicillium sp., and (C) Rhizopus spp. Development of zygospore and its germination.



Fig. 4. (A) Bacillus subtilis and Staphylococcus aureus.

PCR amplification was done utilizing **forward primer** (5'AGA GTT TGA TCC TGG CTC AG'3), reverse primer (5'GGT TAC CTT GTT ACG ACT T 3) (Lane, 1991). PCR was performed using the recommended thermal cycling conditions as a follow: initial step for 10 min at 95 °C. Denaturation for 30 sec. at 95 °C. Annealing at 65 °C for 1 min. 35 rounds of 90-second extension at 72 °C. The extension time was 10 min. at 72 °C. Utilizing PCR products on agarose 1 %agarose gel against 1 Kb plus ladder (Thermo Fisher Scientific). BLAST analysis was then performed on the bacterial isolates' DNA sequences (Clarridge, 2004).

2.6. Molecular Identification of fungi by 18S rRNA

A) DNA Extraction:

Using molecular ITS regions, fungi were detected. Each fungal isolate was grown in PDA for one week at 25 $^\circ$ C. Each sample's DNA was



Fig. 5. Gram positive bacteria isolated from high-quality products (A) *Bacillus* sp. and (B) *Staphylococcus* sp.

isolated using a Quick-DNATM Fungal/Bacterial Miniprep Kit (Zymo Research) according to the manufacturer's instructions.

B) ITS-PCR:

ITS4 was amplified using **forward primers (5'-TCCGTAGGT-GAACCTGCGG-3')** and **reverse primers (5'-TCCTCCGCTTATTGA-TATGC-3')** in PCR reactions using 20 ng genomic DNA in a total volume of 25 L. The temperature profile for PCR amplification was as follows: a 2 min warm-up at 94 °C, at 94 °C for 60 sec. 40 cycle were done, 90 sec. at 52 °C, and 2 min at 72 °C, and a final step of 7 minutes at 72 °C. The 1 % agarose gel was prepared and ran as indicated above. The fungus isolates' DNA sequences were then BLAST-ed.

API-20E kit was used for biochemical testing of bacterial isolates.

Bacterial Isolate	Gram stain	Catalase test	Oxidase test	Citrate test	Indole test	H ₂ S production	Urea test	Sugar Fermentation test	Gelatin hydrolysis test
Bacillus subtilis	Gram positive	+ve	+ve	-ve	-ve	-ve	+ve	-ve	+ve
E. coli	Gram Negative	+ve	-ve	-ve	+ve	-ve	-ve	+ve	-ve
Staphylococcus aureus	Gram positive	+ve	- ve	+ve	-ve	-ve	+ve	+ve	+ve
Staphylococcus epidermidis	Gram positive	+ve	-ve	+ve	-ve	+ve	+ve	+ve	-ve
Streptococcus pneumonia	Gram positive	-ve	-ve	+ve	-ve	+ve	-ve	+ve	+ve
pseudomonas aeruginosa	Gram Negative	+ve	+ve	+ve	-ve	-ve	-ve	-ve	+ve

Table 10

The matching ratio of bacterial and fungal isolates in the NCBI database.

Match ratio	Organism
99 %	Bacillus subtilis
99 %	Escherichia coli
99 %	Staphylococcus aureus
99 %	Staphylococcus epidermidis
99 %	Streptococcus pneumonia
99 %	pseudomonas aeruginosa
99 %	Aspergillus fumigatus
99 %	Aspergillus niger
99 %	Penicillium citrinum
99 %	Rhizopus arrhizus

3. Results

A Total of 50 samples of cosmetics were collected from different shops in Mecca region. Saudi Arabia. Samples were isolated on four different media (Potato dextrose agar, Blood agar, MacConkey agar, and Nutrient agar). Collected samples were divided into two groups regarding to their quality. Low - quality brands in Table 1 and high-quality brands in Table 2.

Generally, results of microbial growth are shown in Table 3 and Table 4 the bacterial out number fungi in terms of growth percentage.

Most of the bacteria that isolated were Gram- positive (Cocci and bacilli), and Gram-negative bacteria such as short bacilli. While fungal isolates were related to genera *Aspergillus*, *Penicillium* and *Rhizopus*.

Table 3 and Chart 1 show the frequency of microbial growth in low quality makeup. It has been observed the most contaminated product was in lip gloss and it follows by the lipstick. It found also, the less growth were in Eye pencil, Eye liner and Eye shadow, and there's no growth in mascara. The bacterial isolates from low- quality cosmetics were *Staphylococcus aureus*, *S. epidermis, Streptococcus pneumonia, Bacillus subtilis*, and *E. coli*. The fungal isolates were, *Rhizopus* sp., *Penicillium* sp., and *Aspergillus* Sp. (Table 4).

The percentages and diversity of bacterial growth is shown in (Chart 2). The most predominant genus of bacteria is *Staphylococcus aureus and E. coli* (27 %), which follows by *Streptococcus pneumonia* (18 %), *Staphylococcus epidermis* (17 %), *Bacilli subtilis* (12 %), and *Pseudomonas aeruginosa* (5 %). In Chart 3 *Aspergillus* sp. is the most predominant fungi (57 %), which follows by *Penicillium* (29 %) and *Rhizopus* (14 %). The highest fungal growth rate was in lip-gloss that isolated from the low-quality cosmetics. In Table 4, high quality cosmetics show less growth of bacteria then low-quality, while there was no growth at PDA. Chart 4 shows the frequency of microbial growth was the highest in mascara, lip-gloss which follows in order by Eye Shadow, Lipsticks, Powders, Plusher, and Concealer. There is no growth of bacterial species in Foundation and

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OR392892.1:62-805 Bacillus sp. (in: firmicutes) strain nsu-10 16S ribosomal RNA gene partial sequence
            OR364145.1:65-808 Bacillus velezensis strain SM2 16S ribosomal RNA gene partial sequence
      70
            OR392901.1:62-805 Bacillus sp. (in: firmicutes) strain nsu-19 16S ribosomal RNA gene partial sequence
      70
            OR392932.1:63-806 Bacillus sp. (in: firmicutes) strain nsu-50 16S ribosomal RNA gene partial sequence
     70
            OR392933.1:66-809 Bacillus sp. (in: firmicutes) strain nsu-51 16S ribosomal RNA gene partial sequence
    70
            OR392937.1:63-806 Bacillus sp. (in: firmicutes) strain nsu-55 16S ribosomal RNA gene partial sequence
    70
            OR392956.1:64-807 Bacillus sp. (in: firmicutes) strain nrh-11 16S ribosomal RNA gene partial sequence
   70
            OR392964.1:64-807 Bacillus sp. (in: firmicutes) strain nrh-19 16S ribosomal RNA gene partial sequence
  70
            OR393026.1:68-811 Bacillus sp. (in: firmicutes) strain nts-58 16S ribosomal RNA gene partial sequence
 70
            MT535848 1:43-786 Bacillus spizizenii strain ATTC 6633 clone E7B1 16S ribosomal RNA gene partial seguence
 70
            MT535853.1:43-786 Bacillus spizizenii strain ATTC 6633 clone M78 16S ribosomal RNA gene partial sequence
70
            OK626682.1:39-782 Bacillus subtilis strain SWAM 8Aq 16S ribosomal RNA gene partial sequence
70
            OQ195797 1:77-820 Bacillus subtilis strain JM1 16S ribosomal RNA gene partial sequence
            OQ598552.1:33-776 Bacillus subtilis strain SY3 16S ribosomal RNA gene partial sequence
            MH767131.1:33-776 Bacillus sp. (in: firmicutes) strain NIORKP47 16S ribosomal RNA gene partial sequence
           MN826200.1:28-771 Bacillus subtilis strain C14 16S ribosomal RNA gene partial sequence
        92 -
           MN421342.1:45-788 Bacillus subtilis strain P4F103 16S ribosomal RNA gene partial sequence
           KT341648.1:17-760 Uncultured bacterium clone b7-25 16S ribosomal RNA gene partial sequence
      34
            MK863566.1:52-795 Bacillus licheniformis strain CRN3 16S ribosomal RNA gene partial sequence
           KX631430.1:58-801 Bacillus subtilis strain P5 16S ribosomal RNA gene partial sequence
```

Fig. 6. Phylogenetic tree of bacterial strain B. subtills isolated from cosmetic product based on 16s rDNA sequence.

86 CP126940.1:477369-477926 Escherichia coli O2:K1:H7 strain APEC E18055 chromosome complete genome
الله المعالم 86 🖉 CP126942.1:468986-469543 Escherichia coli O1:K1:H7 strain APEC E18006 chromosome complete genome
⁸⁶ CP126937.1:1347972-1348529 Escherichia coli O2:K1:H4 strain APEC E19019 chromosome complete genome
⁶⁴ CP126937.1:496167-496724 Escherichia coli O2:K1:H4 strain APEC E19019 chromosome complete genome
⁶⁴ CP126926.1:503149-503706 Escherichia coli O2:K1:H5 strain APEC E19035 chromosome complete genome
⁶³ CP101741.1:2147653-2148210 Escherichia coli strain FY26 chromosome complete genome
100 CN753781.1:15-572 Escherichia coli strain BTMB4 16S ribosomal RNA gene partial sequence
GP126926.1:1381221-1381778 Escherichia coli O2:K1:H5 strain APEC E19035 chromosome complete genome
33 CP126940.1:1343141-1343698 Escherichia coli O2:K1:H7 strain APEC E18055 chromosome complete genome
CP126940.1:4006724-4007281 Escherichia coli O2:K1:H7 strain APEC E18055 chromosome complete genome
- CP126926 1:4042472 4043029 Escherichia coli O2:K1:H5 strain APEC E19035 chromosome complete genome
CD126027 1:2916624 2917101 Ecohorishia coli O2:K1:H4 strain ABEC E10010 shremosoma complete genome
40 [CP126937.1.3610034-3617191 Escherichia coli O2:K1:H4 strain APEC E19019 chromosome complete genome 22] 40 CP126937.1:4592038-4592595 Escherichia coli O2:K1:H4 strain APEC E19019 chromosome complete genome
CP126940.1:4957287-4957844 Escherichia coli O2:K1:H7 strain APEC E18055 chromosome complete genome
²² CP126942.1:4794558-4795115 Escherichia coli 01:K1:H7 strain APEC E18006 chromosome complete genome
²² CP126940.1:5075688-5076245 Escherichia coli O2:K1:H7 strain APEC E18055 chromosome complete genome
CP126940.1:4782610-4783167 Escherichia coli O2:K1:H7 strain APEC E18055 chromosome complete genome
CP126937.1:4844950-4845507 Escherichia coli O2:K1:H4 strain APEC E19019 chromosome complete genome
CP126937.1:4551864-4552421 Escherichia coli O2:K1:H4 strain APEC E19019 chromosome complete genome
CP126926.1:4920939-4921496 Escherichia coli O2:K1:H5 strain APEC E19035 chromosome complete genome
16 CP126926.1:4961109-4961666 Escherichia coli O2:K1:H5 strain APEC E19035 chromosome complete genome
¹⁶ μ ₁₆ CP126926.1:5131807-5132364 Escherichia coli O2:K1:H5 strain APEC E19035 chromosome complete genome
¹⁰ μ ₁₆ [CP126926.1:5250208-5250765 Escherichia coli O2:K1:H5 strain APEC E19035 chromosome complete genome
16 ⁴ CP126940.1:4822779-4823336 Escherichia coli O2:K1:H7 strain APEC E18055 chromosome complete genome
CP126937.1:4726552-4727109 Escherichia coli O2:K1:H4 strain APEC E19019 chromosome complete genome

Fig. 7. Phylogenetic tree of bacterial strain E. coli isolated from cosmetic product based on 16s rDNA sequence.

39 Г	CP123740.1:2615858-2616409 Staphylococcus aureus strain 2.3b chromosome complete genome
39_[L	CP123741.1:1873076-1873627 Staphylococcus aureus strain 2.2 chromosome complete genome
39	CP123739.1:2302950-2303501 Staphylococcus aureus strain 2.5 chromosome complete genome
39	CP123739.1:2258973-2259524 Staphylococcus aureus strain 2.5 chromosome complete genome
39	CP123739.1:2253762-2254313 Staphylococcus aureus strain 2.5 chromosome complete genome
39	CP123738.1:1867707-1868258 Staphylococcus aureus strain 2.6 chromosome complete genome
53	CP115477.1:2151097-2151648 Staphylococcus aureus strain HP20814-043 chromosome complete genor
	CP123738.1:2085696-2086247 Staphylococcus aureus strain 2.6 chromosome complete genome
100 61 [CP123740.1:68463-69014 Staphylococcus aureus strain 2,3b chromosome complete genome
	CP123741.1:2091065-2091616 Staphylococcus aureus strain 2.2 chromosome complete genome
57	CP123738.1:2199230-2199781 Staphylococcus aureus strain 2.6 chromosome complete genome
	CP123740.1:181996-182547 Staphylococcus aureus strain 2.3b chromosome complete genome
39 54	CP123741.1:2204598-2205149 Staphylococcus aureus strain 2.2 chromosome complete genome
	CP123739.1:561053-561604 Staphylococcus aureus strain 2.5 chromosome complete genome
l d'	CP123739.1:674586-675137 Staphylococcus aureus strain 2.5 chromosome complete genome
	CP115476.1:508986-509537 Staphylococcus aureus strain HP20814-006 chromosome complete genome
	CP123738.1:462705-463256 Staphylococcus aureus strain 2.6 chromosome complete genome
	CP123738.1:506682-507233 Staphylococcus aureus strain 2.6 chromosome complete genome
39	CP123739.1:892576-893127 Staphylococcus aureus strain 2.5 chromosome complete genome
39	CP123740.1:1205505-1206056 Staphylococcus aureus strain 2.3b chromosome complete genome
100	CP123740.1:1249482-1250033 Staphylococcus aureus strain 2.3b chromosome complete genome
100	CP123740.1:1254693-1255244 Staphylococcus aureus strain 2.3b chromosome complete genome
100	CP123741.1:462705-463256 Staphylococcus aureus strain 2.2 chromosome complete genome
100 L 100 L	CP123741.1:506682-507233 Staphylococcus aureus strain 2.2 chromosome complete genome
1001	CP123741.1:511893-512444 Staphylococcus aureus strain 2.2 chromosome complete genome

Fig. 8. Phylogenetic tree of bacterial strain S. aureus isolated from cosmetic product based on 16s rDNA sequence.

Eye pencil.

Tables 5, 6 and Chart 5 show the most predominant genus of bacteria is *Staphylococcus aureus* with 41 %, which follows by *Bacilli subtilis* and *Pseudomonas aeruginosa* and *E. coli* with 17 %. *Streptococcus pneumonia* is the less dominant with 5 %.

Most of the bacteria that isolated were Gram-positive (cocci and bacilli), and in Gram-negative bacterial isolates (*Bacilli*, and short *bacilli*). Table 7 shows the average of the total counts of colony in low quality brands as (CFU/ ml). In low quality brands, the lip gloss and lipstick recorded high numbers than other products for bacterial isolates with ($300X10^{-5}$ and 251×10^{-5}) while fungal isolates recoded low percentage number less than 10 colonies in most low-quality brands except plusher. Table 8 shows the average of the total counts of colony in high quality brands which indicates the decrease of microbial population compared to low quality brands, mascara recoded the highest numbers with (300×10^{-5}) while no fungal growth observed in all products.

According to morphological and microscopic characters, bacteria were identified based on the reaction of gram stain and the arrangement

of bacteria. Gram positive bacteria that isolated from low-quality makeup are shown in Fig. 1, Fig. 2, Fig. 3. While fungi isolates were identified by morphological cultures and microscopic detection by observing mycelium and spores' arrangement on pores or sporangium or vesicles. Fungal cultures are shown in Fig. 4, Fig. 5.

3.1. Identification of bacteria by biochemical tests

Bacteria were identified using the biochemical assays described in Table 9. and the findings were Bergey's handbook compared, which showed the following microbes: *Escherichia coli, Streptococcus pneumonia, Bacillus subtilis, Staphylococcus aureus, pseudomonas aeruginosa, and Staphylococcus epidermidis.*

3.2. Bacterial and fungi molecular identification

The resultant sequences of bacteria's 16 srRNA and fungi's ITS were aligned in the NCBI database, and matched sequences were supported



Fig. 9. Phylogenetic tree of bacterial strain S. epidermis isolated from cosmetic product based on 16s rDNA sequence.



Fig. 10. Phylogenetic tree of bacterial strain S. pnenmoniae isolated from cosmetic product based on 16s rDNA sequence.

and identified, by earlier biochemical studies. Based on the matching ratio of sequencing of bacterial and fungal isolates, as shown in Table 10 below, Phylogenetic tress for each isolate is shown in Figs. 6–15.

4. Discussion

The majority of the isolated microorganisms in this investigation were pathogens found in unused cosmetics. Even though these products are new brands and have never been used, the risk of microbiological infection was considerable. The results showed that both high-quality and low-quality cosmetic samples were contaminated with fungus and germs. Gram positive cocci such *Staphylococci*, *Streptococci*, and *Bacilli* were among the isolated microorganisms. Moreover, short bacilli are preferred by gramme negative bacteria. While isolates of fungi from the Rhizopus, Penicillium, and Aspergillus genera.

In general, high-quality brands exhibit less contamination than lowquality ones; this may be related to the products' ingredients, the way preservatives are applied, the circumstances of transit and storage. The most prevalent genus was *Staphylococci*, which was discovered in both high- and low-quality samples with a frequency of (41 %) both. Numerous research has established that *Staphylococcus* sp. is present in various cosmetic items. Some of these strains are dangerous and bring on skin conditions like desquamate and acne (Dadashi & Dehghanzadeh, 2016) and (El-Tablawy, 2009). Additionally, a study by Noor et al., 2020 discovered that *staphylococci* were the most typical species isolated from a variety of cosmetic tests.

Another potentially hazardous organism was identified during this examination, called *Bacillus*. *Bacillus* causes localized necrotizing







Fig. 12. Phylogenetic tree of fungal strain A. fumigatus isolated from cosmetic product based on 18s rRNA sequence.

cellulitis in the skin, making it risky to use eye cosmetics that have Bacillus contamination (Dadashi & Dehghanzadeh, 2016). According to a 2019 study by Bashir and Lambert, cosmetic regulations expressly state that products shouldn't contain pathogenicity's organisms. Between 70 and 90 percent of the products were contaminated with germs. Fungi also are pathogenic organisms, in low quality cosmetics items Aspergillus, Rhizopus and Penicillium were recovered. Penicillium sp. was the most abundant organism in other research, appearing in 75 % of samples in the study of (De oliveira et al., 2020). Due to their involvement in the synthesis of mycotoxins, particularly ochratoxin A and citrinin, Penicillium represent a risk to human health. Additionally, both mycotoxins are extremely nephrotoxic at micromolar doses (Geisen et al., 2018). Filamentous fungus can utilize the humidity of the environment to assure growth on the surfaces of cosmetics with low quantities of water, such foundation, qualifying these goods as semi-aqueous preparations. This implies that moisture promotes the growth of filamentous fungus. Despite the fact that there was a lot of water in those preparations (Oliveira et al., 2020).

In Saudi Arabia, Nasser (2008) investigated the microbial contamination in 75 cosmetic samples. She discovered that lip cosmetic products had the highest fungal counts, and the samples were infected with 13 and 24 mesophilic and thermophilic fungus species from 2 and 6 genera, respectively. The most common fungal genus was *Aspergillus*, and 36.7 % of the analyzed samples were contaminated with *E. coli*, while *Bacillus* and *Pseudomonas* were commonly observed (Okeke and Lamikanra, 2001). From a cosmetic manufacturing facility, *Pseudomonas aeruginosa* and *Enterobacter gergovia* were identified, and these microorganisms demonstrated increased resistance to formaldehyde-releasing preservatives and parabens (Ferrarese et al., 2003). The risk of infection from these germs, which can infect the lips or eyes, is very high (Bashir and Lambert, 2020; Burleson and Martinez-Vaz, 2011).

On the other hand, because nature can encourage microbial growth

00343722 11.552 Aspercillus ricer isolate MSA1 internal transcribed spacer 1 partial sequence 5.8S ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence 5.8S ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence 5.8S ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence 5.8S ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence 5.8S ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence 5.8S ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence 5.8S ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial 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Fig. 13. Phylogenetic tree of fungal strain A.niger isolated from cosmetic product based on 18s rRNA sequence.



Fig. 14. Phylogenetic tree of fungal strain R. arrhizus isolated from cosmetic product based on 18s rRNA sequence.

in cosmetics, which can lead to infection, these products are more likely to be contaminated by microorganisms than those that don't contain water. (Halla et al., 2018 & Skowron et al., 2017). Water that hasn't been sterilized or treated can encourage bacterial growth, which can contaminate cosmetics. Additionally, cosmetics can serve as a nutritious environment for the growth of microorganisms. (Alwan, 2018). Microbial contamination, according to (Choubey & Godbole, 2017) can occur during the manufacturing process, in raw materials, during consumer usage of the product, or as a result of dust in retail marketplaces. After a product has been opened, the consumer's hands or the surroundings may contaminate it further.

Due to the creation of hazardous bacteria metabolites and product degradation, cosmetic product contamination can directly affect human health. Therefore, maintaining the sanitary standards of the product and ensuring consumer safety depend on the microbiological preservation of cosmetics (Choubey & Godbole, 2017). It is generally known that microorganisms have the capacity to multiply and proliferate in cosmetic products. Cosmetics include a variety of components, including sugar, vitamins, proteins, oils, and water, all of which are necessary for the growth of microbes (Ahmida et al., 2018). According to (Wilson et al., 1975), climatic variables like temperature variation and moisture from humidity promote microbial growth in cosmetic goods.

(Ahmida et al., 2018) recommended Keep cosmetics in a dry, cool environment to prevent spoiling, shield consumers from infections, and lengthen the shelf life of your items. A good preservative system, as described by (Nuzhath, 2014 will prevent quick postproduction contamination, resulting in acceptable low levels of microorganisms in the preparation and so making it safe for consumers, which in this case is ineffective. Cosmetics that have been contaminated by microbes run the risk of breaking down and costing consumers money. As a result, it's

OQ632578.117-524 Penicillium citrinum strain GXIMD02052 internal transcribed spacer 1 partial sequence 5.85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial sequence S 85 ribosomal RNA gene and internal transcribed spacer 2 complete sequence and large subunit ribosomal RNA gene partial s

Fig. 15. Phylogenetic tree of fungal strain Penicillium citrinum isolated from cosmetic product based on 18s rRNA sequence.

crucial to guarantee that cosmetic goods are bacteria free, and the preservatives used in them should be able to kill any potential microbes (Siya et al., 2019).

5. Conclusion

Microbial contamination of cosmetic products is a matter of great importance to the industry, and it is potentially a major cause of economic losses. Water and some ingredients support microbial growth. The results of this study indicated that all samples in high-quality and low-quality brands show bacterial and fungal growth more than the acceptable number prescribed by FDA and other legislations. The highquality of cosmetics doesn't mean the high price only, it means selection a good raw material, offering a good storage and transport, and have preservation system which may reduce microbial growth. For consumers, we recommend sterilizing these items with a good sanitizer. Our vision is to keep searching for more studies in cosmetics microbiology discuss the microbial contamination and solutions to reduce it.

Declaration of competing interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

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